

FIG. 1

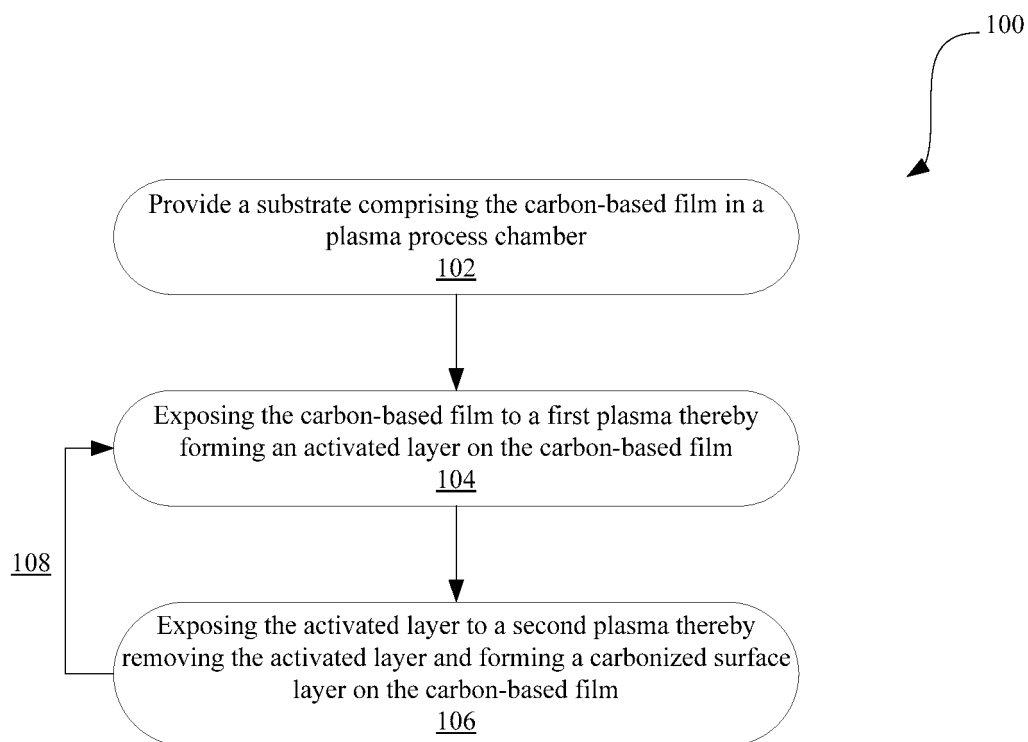


FIG. 2

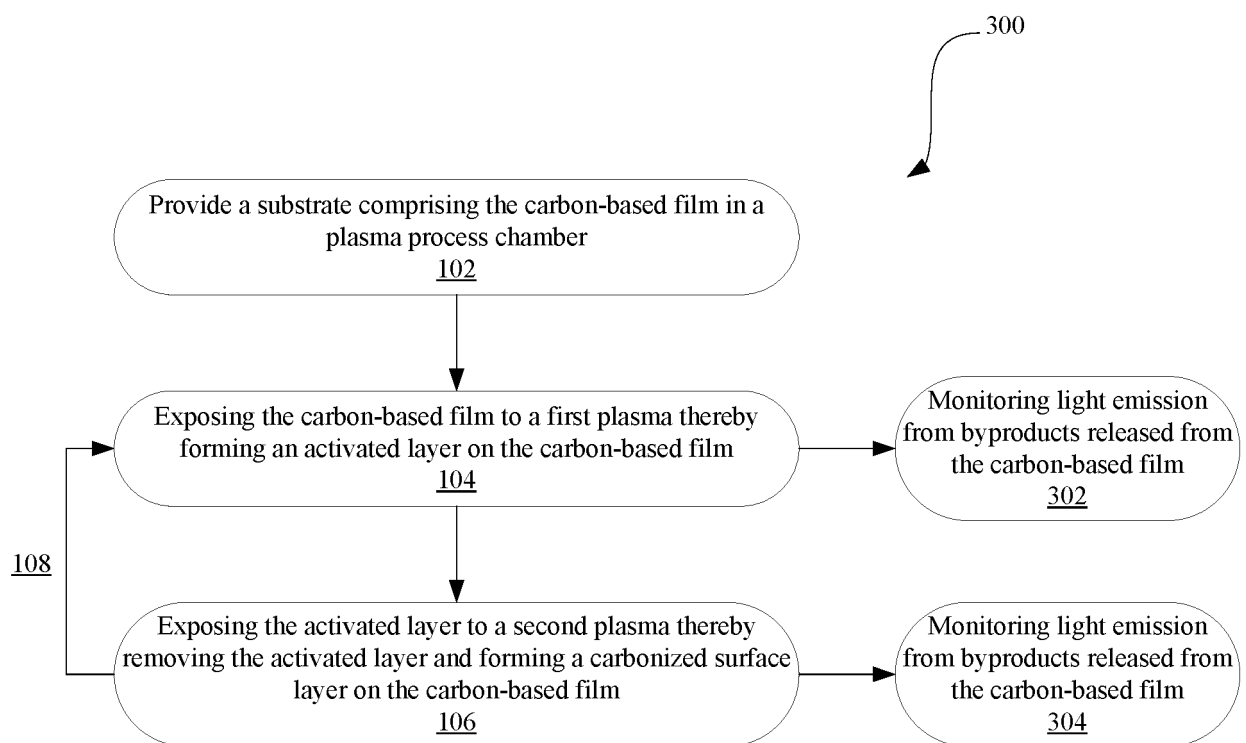


FIG. 3

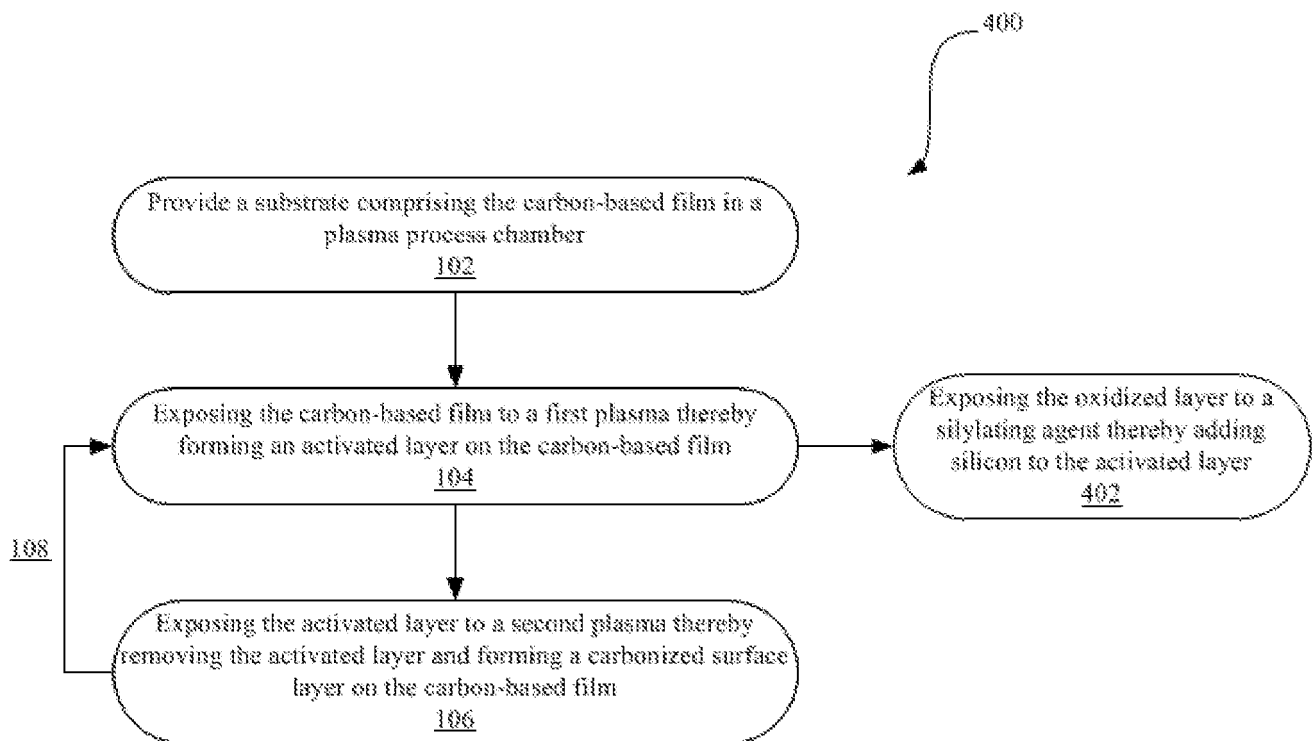
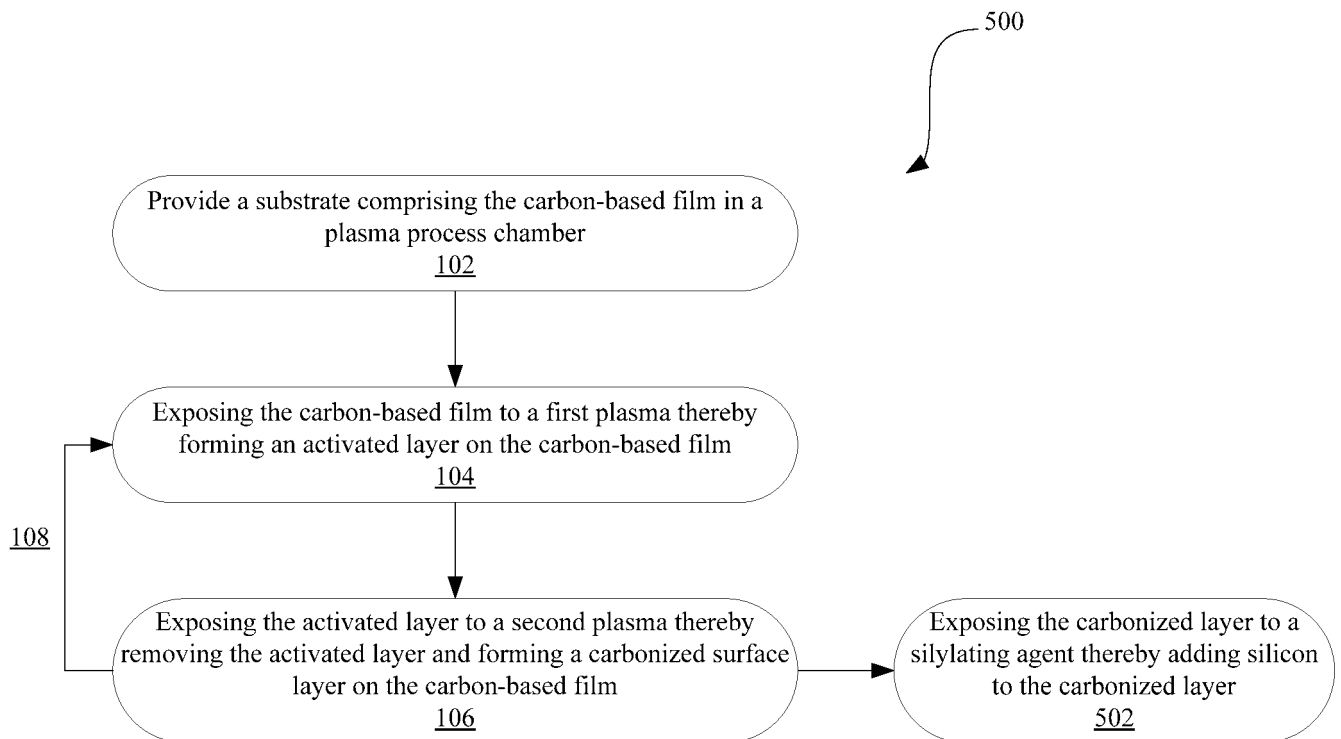


FIG. 4



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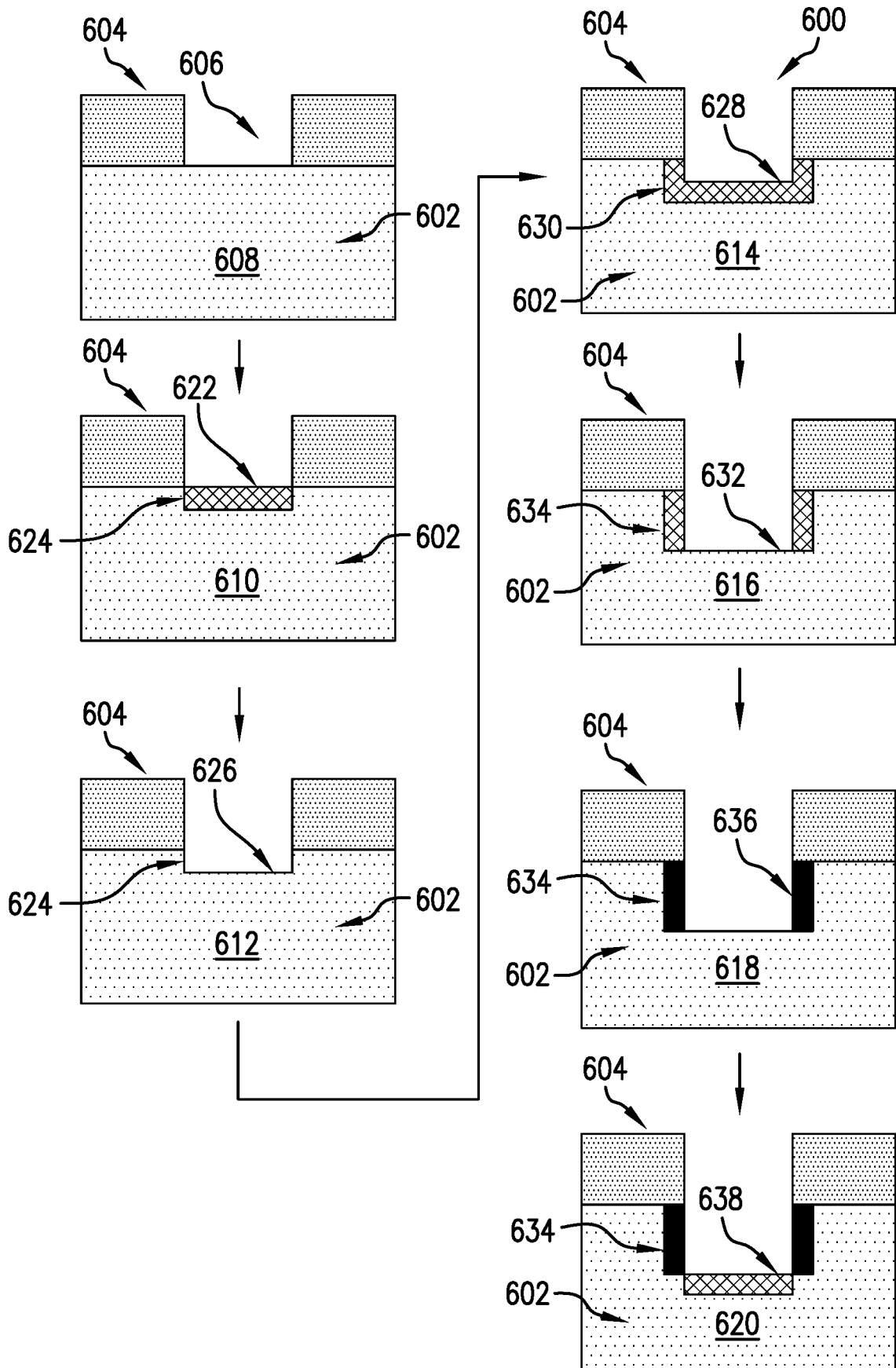
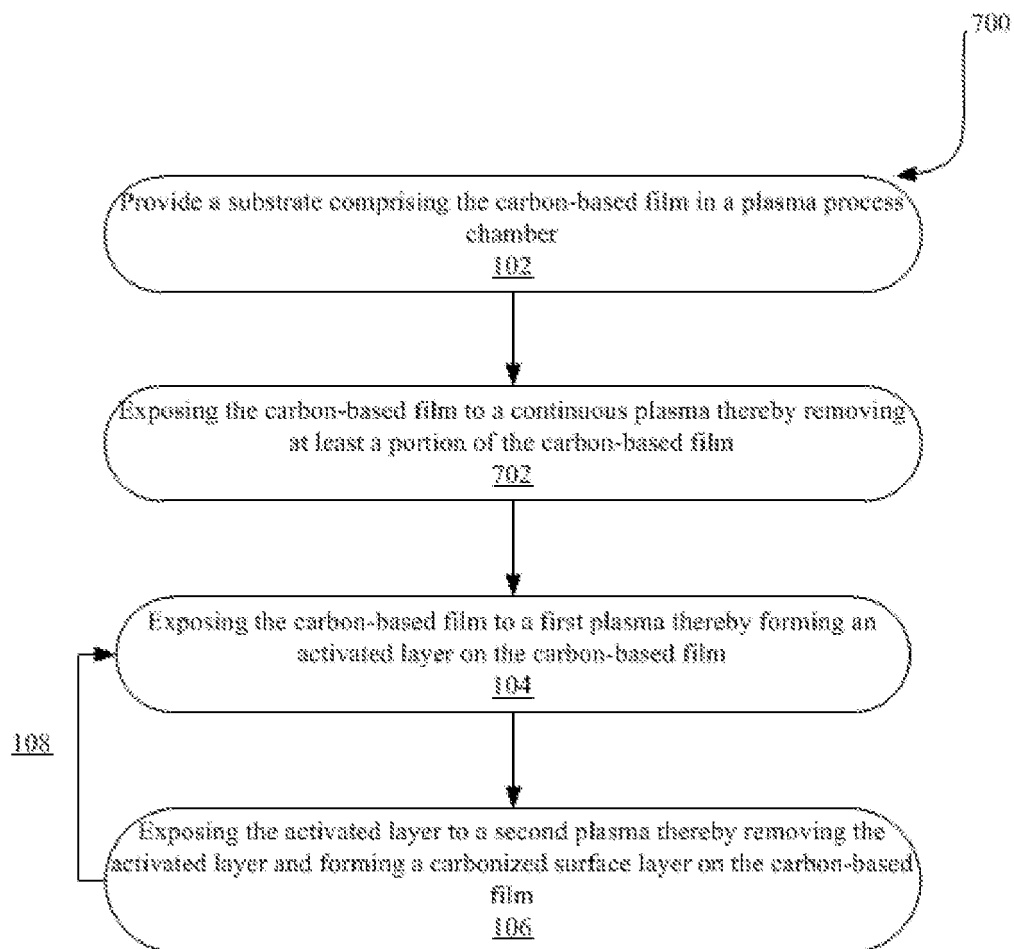


FIG. 5

FIG. 6



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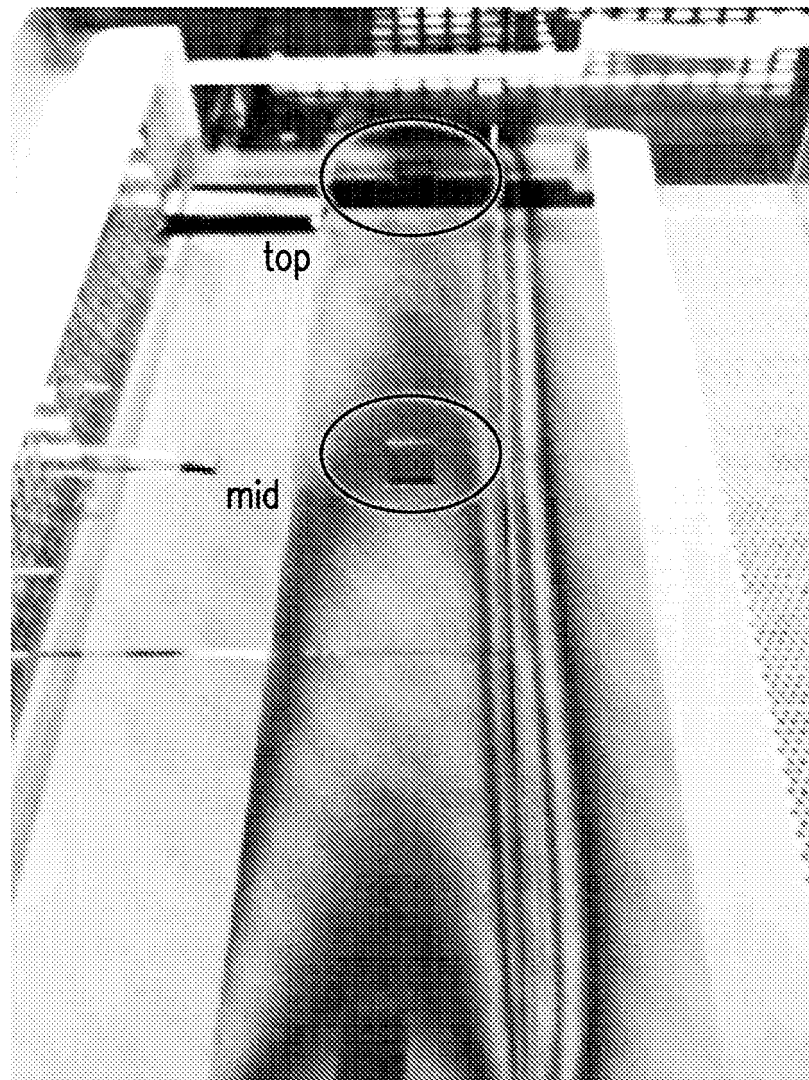
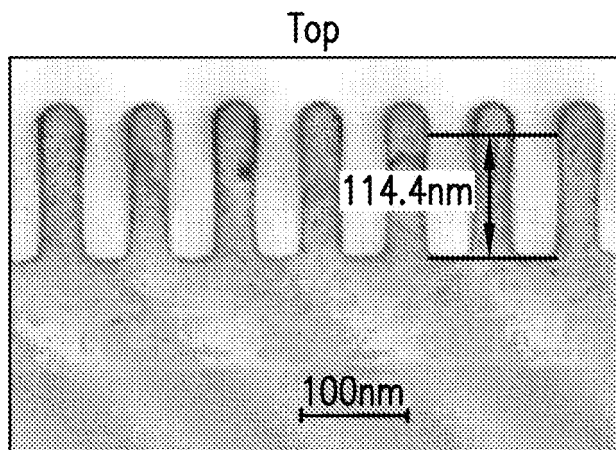
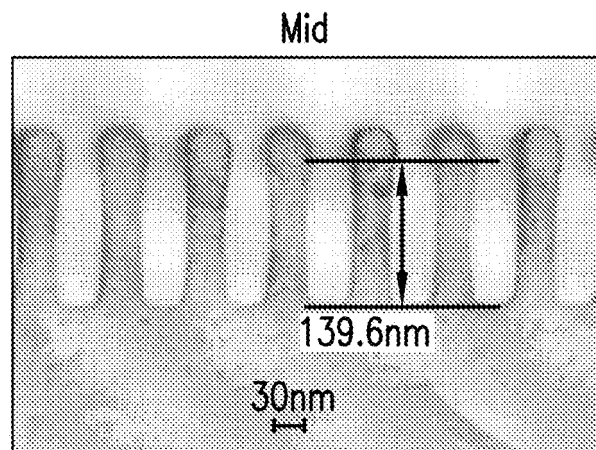
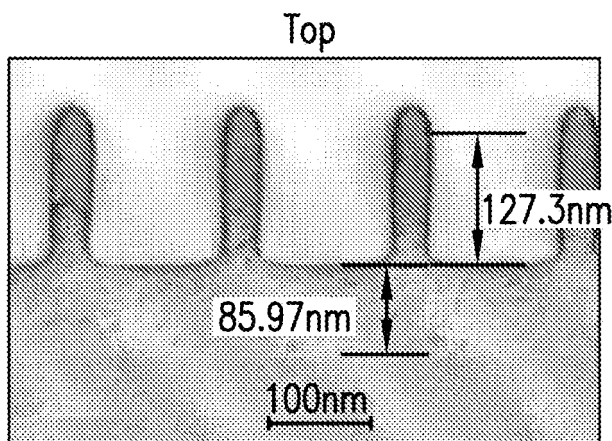
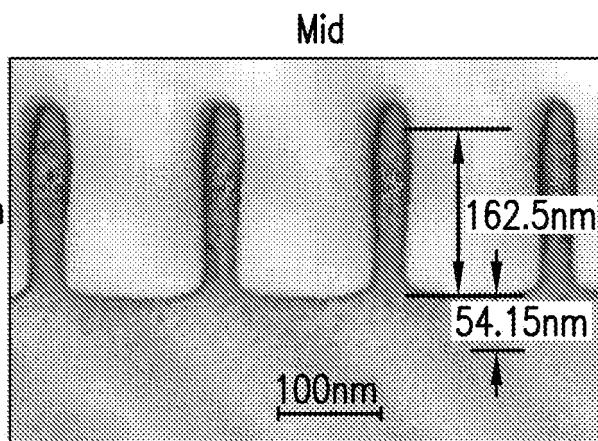
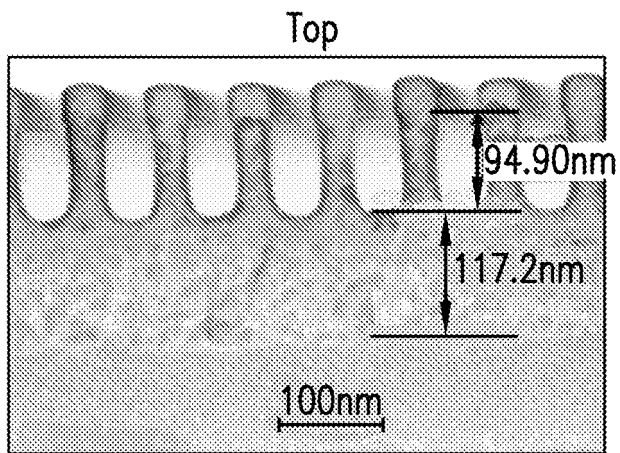
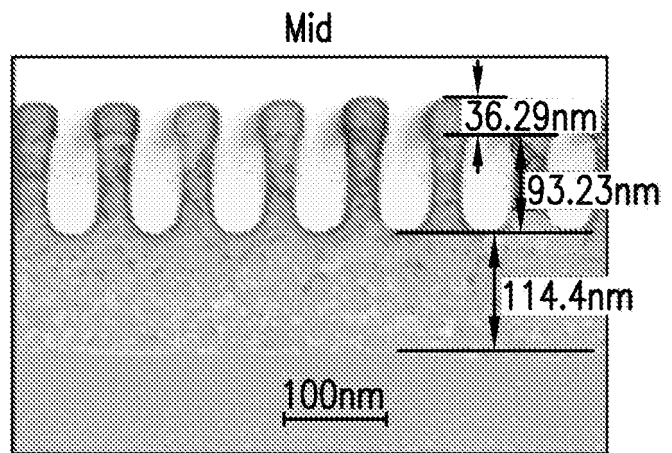
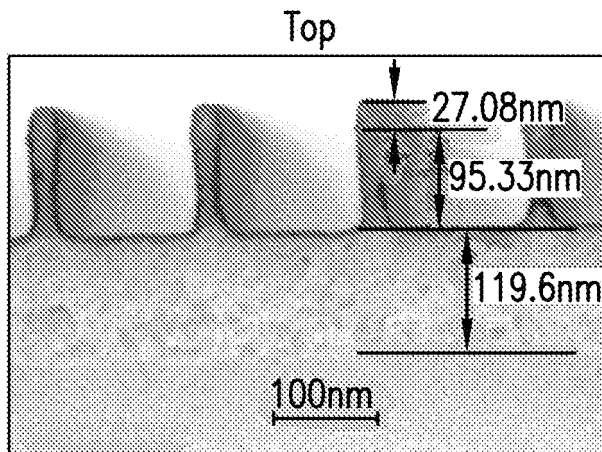
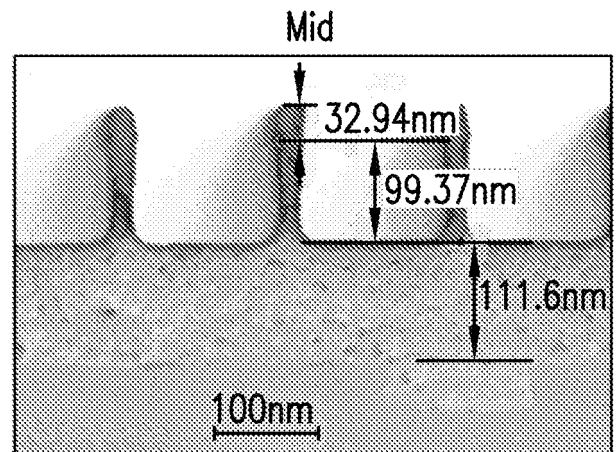


FIG. 7

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**FIG.8A****FIG.8B****FIG.8C****FIG.8D**

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**FIG.9A****FIG.9B****FIG.9C****FIG.9D**

Exemplary cyclic etch and CW etch parameters (13 MHz plasma)

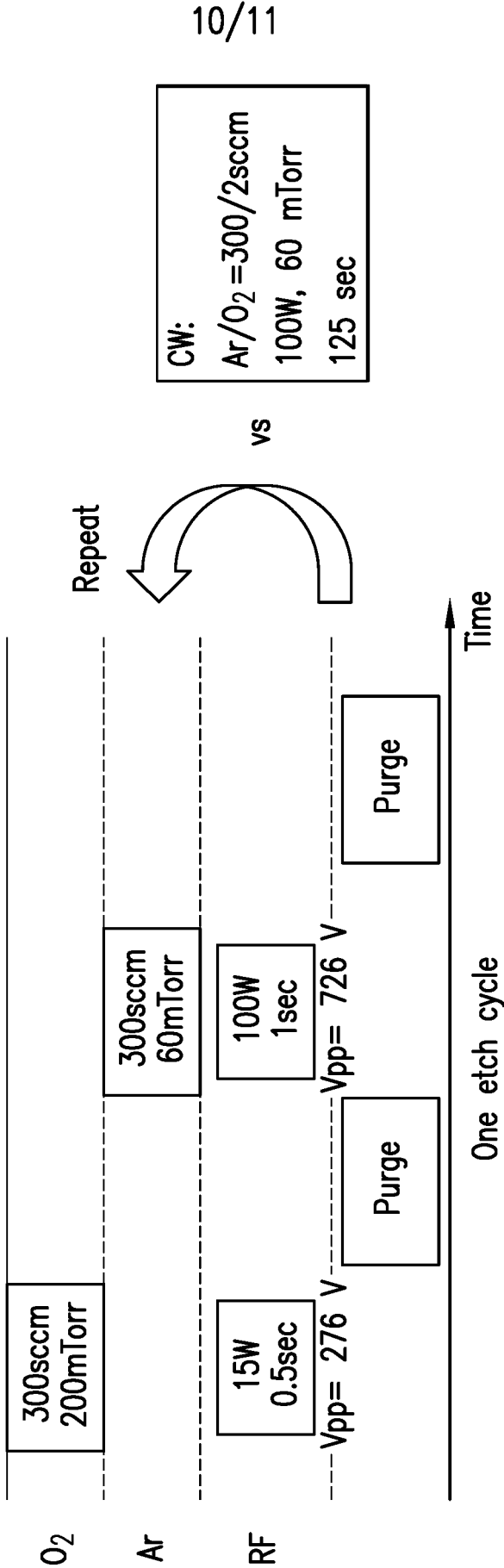


FIG.10

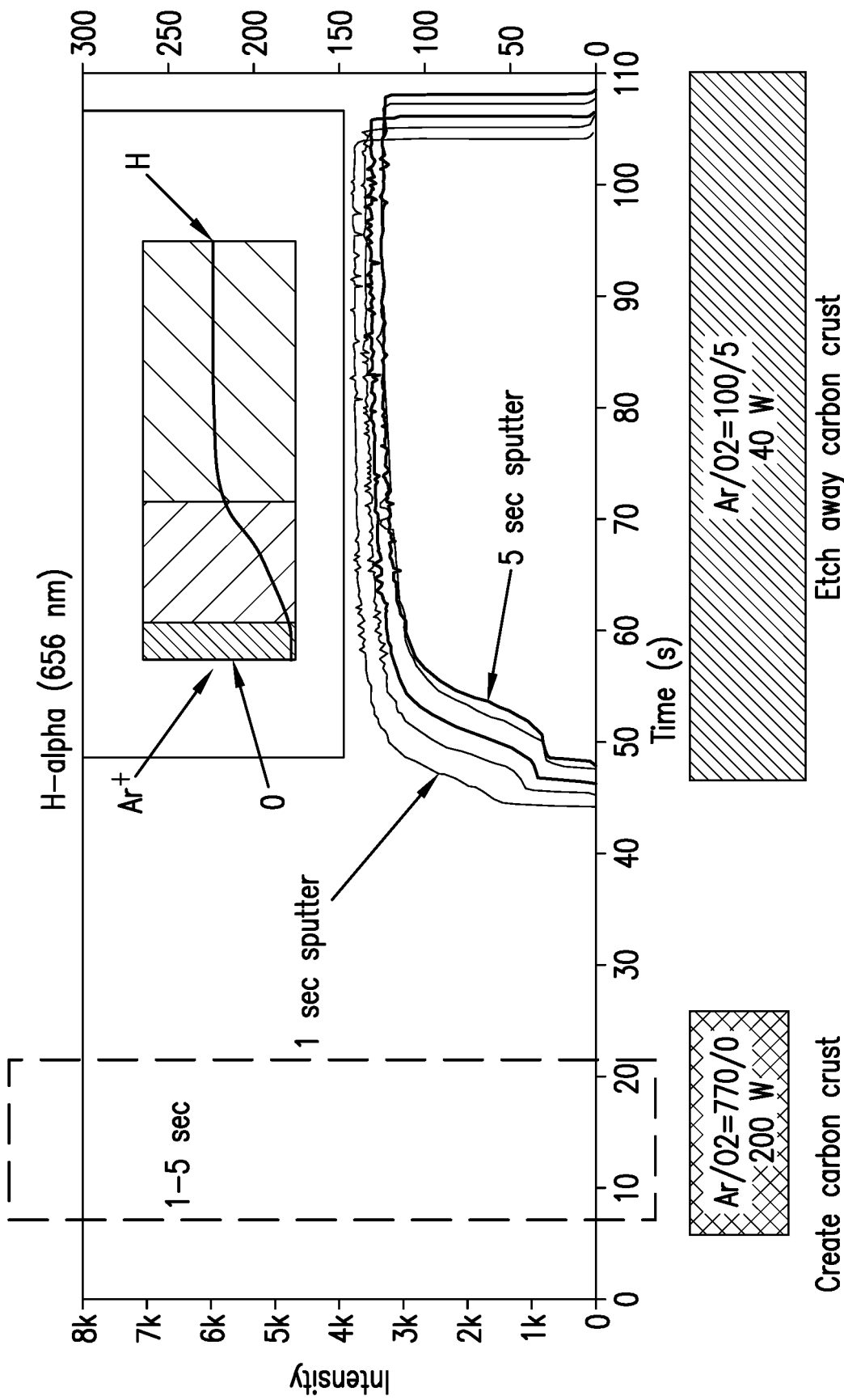


FIG.11